ATITISE

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## RECEIVED

DEC 3 1 2003

TC 1700

PATENT 30205/37328

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Min Ho Jung et al.

Serial No.: 09/878,803

Filed: June 11, 2001

For: Additive for Photoresist

Composition for Resist Flow Process

Group Art Unit: 1752

Examiner: Yvette C. Thornton

I hereby certify that this paper and the documents referred to as enclosed therewith are being deposited with the United States Postal Service as first class mail, postage prepaid, on **December 18**, 2003, in an envelope addressed to Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450

Michael R Hull Reg. No. 35,902

Attorney for Applicants

## **AMENDMENT AFTER FINAL (37 C.F.R. § 1.116)**

Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

Please enter the following amendment in the above-referenced patent application.